

L Number	Hits	Search Text	DB	Time stamp
1	3	chamber near3 clean\$3 and sublimat\$3 and (organic near EL oled) and scan\$4	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/09/01 06:47
4	119	chamber and sublimate and light and scan\$4	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/09/01 06:51
5	0	chamber and sublimate and light and scan\$4 and oled	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/09/01 06:52
6	4	chamber and sublimate and light and scan\$4 and (EL oled)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/09/01 07:15
7	18	chamber and laser near3 scan\$4 near12 throughput	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/09/01 07:30
8	0	sublimation near12 laser near3 scan\$4 near12 throughput	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/09/01 07:31
9	12	sublimation near12 laser near3 scan\$4	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/09/01 09:00
10	5	("6559036").PN.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/09/01 09:06
11	2	("6294892").PN.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/09/01 09:06
12	1	ulvac.as. and "342653"	USPAT	2003/09/01 09:11
13	1		USPAT	2003/09/01 09:11
14	1		USPAT	2003/09/01 09:11
15	1		USPAT	2003/09/01 09:11
16	1		USPAT	2003/09/01 09:12
17	0		USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/09/01 09:38
18	23	"342653"	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/09/01 09:39
19	21	"168559"	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/09/01 09:40
20	0	"10-168559"	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/09/01 09:40

21	20	"organic thin film forming".ti.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/09/01 09:41
-	3450	"electro-optical device"	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/03/07 15:34
-	1411	"electro-optical device" and manufactur\$4	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/01/06 13:30
-	1226	"electro-optical device".ti.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/01/06 13:31
-	416	"electro-optical device".ti. and manufactur\$4	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/03/07 15:40
-	3	yamazaki.in. and takayama.in. and fukunaga.in.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/03/07 15:34
-	0	"electro-optical device" and UV and (infrared IR) and plasma and (irradiating irradiated irradiat) and exhaust\$3 and (sublimate sublimating sublimated) and "organic light emitting"	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/03/07 15:44
-	2	"electro-optical device" and UV and (infrared IR) and plasma and (irradiating irradiated irradiat) and exhaust\$3 and (sublimate sublimating sublimated "organic light emitting")	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/03/08 08:39
-	518	chamber and (light infrared ultraviolet visible (radiation light) near3 (nm nanometer)) and (sublimate sublimating sublimation) and (exhaust exhausting exhausted)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/03/08 08:44
-	1	chamber near55 (light infrared ultraviolet visible (radiation light) near3 (nm nanometer)) near99 (sublimate sublimating sublimation) near99 (exhaust exhausting exhausted) and vapor near3 deposition	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/03/08 08:47
-	157	chamber and (light infrared ultraviolet visible (radiation light) near3 (nm nanometer)) and (sublimate sublimating sublimation) and (exhaust exhausting exhausted) and vapor near3 deposition	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/03/08 09:07
-	1	chamber and (light infrared ultraviolet visible (radiation light) near3 (nm nanometer)) and (sublimate sublimating sublimation) and (exhaust exhausting exhausted) and vapor near3 deposition and halogen and plasma and oxygen near5 plasma and (organic near3 light near2 (emit emitted emitting))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/03/08 09:14
-	1	chamber and (light infrared ultraviolet visible (radiation light) near3 (nm nanometer)) and (sublimate sublimating sublimation) and (exhaust exhausting exhausted) and vapor near3 deposition and halogen and plasma and oxygen near5 plasma and organic near3 light	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/03/08 09:16

-	10	chamber and (light infrared ultraviolet visible (radiation light) near3 (nm nanometer)) and (sublimate sublimating sublimation) and (exhaust exhausting exhausted) and vapor near3 deposition and halogen and plasma and oxygen near5 plasma	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/03/08 09:28
-	0	chamber and (light infrared ultraviolet visible (radiation light) near3 (nm nanometer)) and (sublimate sublimating sublimation) and (exhaust exhausting exhausted) and halogen and plasma and oxygen near25 plasma and chamber.ti. and clean\$3.ti.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/03/08 09:30
-	7098	chamber.ti. and clean\$3.ti.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/03/08 09:30
-	82	chamber.ti. and clean\$3.ti. and (exhaust exhausting exhausted) and vapor near3 deposition	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/03/08 09:38
-	69	chamber.ti. and clean\$3.ti. and (exhaust exhausting exhausted) and vapor near3 deposition and plasma	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/03/08 09:42
-	22	chamber.ti. and clean\$3.ti. and (exhaust exhausting exhausted) and vapor near3 deposition and ("o.sub.2" oxygen) near20 plasma	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/09/01 06:51
-	0	electroluminescent and "cracker Jack"	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/03/08 10:41
-	18	(electroluminescent electro near1 luminescent) near12 organic and chamber near clean\$3	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/03/08 10:58
-	1	"6034755".PN.	USPAT	2003/03/08 10:55
-	1	"6020078".PN.	USPAT	2003/03/08 10:55
-	1	"6001413".PN.	USPAT	2003/03/08 10:55
-	1	"5963826".PN.	USPAT	2003/03/08 10:55
-	1	"5817431".PN.	USPAT	2003/03/08 10:55
-	1	"5792326".PN.	USPAT	2003/03/08 10:55
-	1	"5674635".PN.	USPAT	2003/03/08 10:55
-	1	"5505985".PN.	USPAT	2003/03/08 10:55
-	1	"4895291".PN.	USPAT	2003/03/08 10:55
-	4	"5789359"	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/03/08 10:58
-	129663	electrooptical.ti. "display device".ti.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/03/08 11:47
-	85	electrooptical.ti. and "display device".ti.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/03/08 11:48
-	4580	(electrooptical electro optical).ti. and "display device".ti.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/03/08 11:48

-	518	(electrooptical electro nearl optical).ti. and "display device".ti.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/03/08 12:22
-	0	"10-168559"	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/03/08 12:23
-	0	10-168559	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/03/08 12:23
-	21	"168559"	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/03/08 12:25
-	24	takayama and (electrooptical.ti. "display device".ti.) and "2001"	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/03/08 12:31
-	24	takayama and (electrooptical.ti. "display device".ti.) and "2001"	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/03/08 12:32
-	23	takayama.in. and (electrooptical.ti. "display device".ti.) and "2001"	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/03/08 12:32
-	0	10-168559	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/03/08 12:32
-	0	jp10-168559	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/03/08 12:33
-	0	8-342653	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/03/08 12:34
-	80	ulvac and "1996" and film and organic	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/03/08 12:35
-	2	chamber and (light infrared ultraviolet visible (radiation light) near3 (nm nanometer)) and (sublimate sublimating sublimation) and (exhaust exhausting exhausted) and vapor near3 deposition and halogen and plasma and oxygen near5 plasma and (organic near3 light near2 (emit emitted emitting))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/08/29 11:33
-	5	chamber and (light infrared ultraviolet visible (radiation light) near3 (nm nanometer)) and (sublimate sublimating sublimation) and (exhaust exhausting exhausted) and vapor near3 deposition and (organic near3 light near2 (emit emitted emitting))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/08/29 11:35

-	122	chamber and (light infrared ultraviolet visible (radiation light) near3 (nm nanometer)) and (sublimate sublimating sublimation) and deposition and (oled organic near3 light near2 (emit emitted emitting))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/08/29 15:41
-	2	"6132280"	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/08/29 15:46
-	3	chamber near3 clean\$3 and sublimat\$3 and halogen and organic near4 light	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/08/29 15:53
-	4	chamber near3 clean\$3 and sublimat\$3 and halogen and (organic near EL oled)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/08/29 15:55
-	7	chamber near3 clean\$3 and sublimat\$3 and (organic near EL oled)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/09/01 06:46